Interaction of H atoms with silicaceous interstellar dust particles: H–Forsterite



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INTRODUCTION

The formation of molecular hydrogen in the ISM is still an open question. Since the early 60's interstellar dust particles are invoked as possible catalysts to explain the large abundance of H₂ in diffuse clouds and PDR edges of dense molecular clouds

•Current knowledge of interstellar dust particles indicate that they have both a **carbonaceous and silicaceous composition**. While several tens of theoretical studies exist for carbonaceous grains, there is only one (QM/MM: embedded cluster) study of H adsorption on silicates: Forsterite [1].

•We present a **periodic DFT study** of the interaction of an H atom with the **Forsterite [010] surface**, with the aim of characterizing the **properties of H atom adsorption** on that surface.

[1] PM. Goumans, C. Richard, A. Catlow and W.A. Brown. MNRAS. 393,1403-1407 (2009)

SETUP: METHOD

- Spin-unrestricted periodic DFT with GGA-PBE and OptB88-VDW [1] functionals using the SIESTA code [2].
- Pseudopotentials.
- Basis: Localized orbitals (LCAO), DZP quality optimized for bulk Forsterite (0.02 GPa).
- Grid/K-points: 450 Ry and 4x4x4 sampling (convergence errors < 0.02 meV)</p>
- NEB: Nudged elastic band (underway).

[1] J. limes, DR. Bowler and A. Michaelides. J. Phys.: Condens. Matter 22, 022201 (2010)
[2] Soler. J. Phys.: Condens. Matter 14, 2745 (2002)

SETUP: BULK

• Forsterite $[Mg_2SiO_4]$ is an end member of the olivines family.



Orthorhombic P_{bnm} (b > c > a)

[4] N. de Leew. J. Phys. Chem. C,105 (2001) [5] M de la Pierre.J. Comp. Chem. 32,9 (2011) *Independent SiO₄ tetrahedra linked by divalent cations in octahedral coordination.*

The divalent cations occupy two distinct crystallographic sites with the oxygen sublattice deviating significantly from the ideal close packing arrangement

SETUP: SURFACE

Cut along the {010} plane [P_{bnm}] and in between two Mg atoms leads to the most stable surface [1].



SETUP: SURFACE

 Minimum number of unit cells chosen in order to correctly describe the surface: through and analysis of DOS, relaxation, Mulliken charges and surface energies.



[1] G. W. Watson et al. Phys. Chem. Minerals
(1997)25:70-78
[2] De Leew et al. Phys. Chem. Miner.27,332-341(2000)

H – PHYSISORPTION (VdW?)



Our objective is to determine the potential energy as H approaches the surface, the easiest way is to make an initial study at different sites without relaxation

■The outer wells are not genuine VDW physisorption: some charge transfer from the atom to the substrate exists → "Strong physisorption/weak chemisorption"



Charge transfer in the outer well: displaced bridge (2Å)



"PHYSISORPTION" - CHEMISORPTION



Allowing the surface to relax, we find, in addition to the outer wells, new features at small H-substrate distance



H chemisorbs nearly atop O [bond distance = 0.99 Å]: the O-H bond is tilted by 19.98° with respect to the normal to the surface.

The Mg and O atoms involved in the chemisorption get displaced towards the H atom:

> Mg {Δx=-0.29 Å, Δy=-0.12 Å, Δz=+0.32 Å} O {Δx=-0.06 Å, Δy=+0.03 Å, Δz=+0.08 Å}.

Induced Charge density.



-3

-2

-1 $E-E_{F}[eV]$

Mon. Not. R. Astron. Soc. 393,1403-1407 (2009)



<u>SPIN DENSITY MAP ($n_{\uparrow} - n_{\downarrow}$).</u>

Local magnetization on the Mg site. The spin is balanced everywhere except on the magnesium.

Scale: Δ n(r)
+0.0000 +0.0028 +0.0056 +0.0084 +0.0112 +0.0140



<u>View of the wavefuntion involved in the process of chemisorption</u>. The hydrogen is injecting and electron in this state located in the top surface layer. This state is a hybrid of s, p_x and p_z orbitals.

CONCLUSIONS

The present results indicate that an H atom can adsorb <u>without barrier</u> on the [010] surface of Forsterite whatever in the outer wells [strong physisorption/weak chemisorption] or in the inner [chemisorption] well.

Pure VDW <u>physisorption is not found</u>: the binding in the outer wells involves some electron transfer from the H atom to the surface [strong physisorption/weak chemisorption binding]. The outer wells depths are deeper than that of H-graphene (≈ 44 meV) by a factor of 2-7. Comparatively, this should considerably increase the residence time of H atoms adsorbed in these wells at typical temperatures of the diffuse ISM.

The present periodic PBE results for chemisorption [well depth, bonding characteristics] agree with the QM/MM-MPWB1K [embedded cluster] ones obtained by Goumans et al. [1].

 NEB calculations are underway to determine the potential energy curve along the minimum energy path. The next stage will consist of studying the interaction of a second H atom with the already chemisorbed one and with the surface in presence of the H chemisorbate.

[1] PM. Goumans, C. Richard, A. Catlow and Wendy A. Brown. Mon. Not. R. Astron. Soc. 393,1403-1407 (2009)

NEB





KBM-No Relax